

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Masahito OSAWA et al.

Group Art Unit : 1793

Appl. No. : 10/598,082 (U.S. National  
Stage Of PCT/JP2005/003229)

Examiner : Fogarty

I.A. Filed : February 21, 2005

Confirmation No. : 9910

For : METHOD FOR PRODUCING Mg-REM-Ni BASED  
HYDROGEN-ABSORBING ALLOY**AMENDMENT UNDER 37 C.F.R. 1.112  
IN RESPONSE TO OFFICE ACTION DATED JANUARY 25, 2010**

Commissioner for Patents  
U.S. Patent and Trademark Office  
Customer Service Window, **Mail Stop Amendment**  
Randolph Building  
401 Dulany Street  
Alexandria VA 22314

Sir:

This is in response to the January 15, 2010 Office Action of the U.S. Patent and Trademark Office setting a three month shortened statutory period for response until April 15, 2010.

Applicants hereby request an extension of time for one month to extend the period for response until May 15, 2010, and are concurrently filing a formal Request for Extension of Time for one month accompanied by the government fee. If for any reason the formal Request for Extension of Time is not associated with the file at the Patent and Trademark Office and/or if any extension of time or fee is necessary to maintain the pendency of the application, this is an express request for any necessary extension of time and authorization to charge any required fee, including any required extension of time and/or claim fee, to Deposit Account No. 19-0089.

**Amendments to the Claims** begin on page 3 of this paper.

**Remarks** begin on page 6 of this paper.

Reconsideration and withdrawal of the rejections of record are respectfully requested in view of the remarks presented herein.